



EXPRESS MAIL NO. EV336597186US

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Leonardi Salvatore
Application No. : 10/033,694
Filed : December 28, 2001
For : INTEGRATION PROCESS ON A SOI SUBSTRATE OF A
SEMICONDUCTOR DEVICE COMPRISING AT LEAST A
DIELECTRICALLY ISOLATED WELL

Examiner : Suk-San Foong
Art Unit : 2823
Docket No. : 856063.721
Date : June 16, 2003

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Commissioner for Patents:

In response to the Office Action dated January 15, 2003, please extend the period of time for response 2 months, to expire on June 15, 2003. Enclosed are a Petition for an Extension of Time and the requisite fee. Please amend the application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 12 of this paper.

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